EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L4	13620	(@ad<"20040126") and "438"/\$.ccls. and ((pattern\$3 or etch\$3) with (gate or polysilicon)) and (gate with (thin\$4 or narrow or slim\$4))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:07
L5	556	I4 and (resist or photoresist or mask) and arc	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:01
L6	6287	l4 and (resist or photoresist or mask) and plasma	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:01
L7	724	l6 and (anti\$reflect\$3 or arc)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:03
L8	292	L7 not l5	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:05
L9	270	(@ad<"20040126") and "438"/72,636, 952.ccls. and ((pattern\$3 or etch\$3) with (gate or polysilicon))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:09
L10	75	I9 and ((pattern\$3 or etch\$3) with (gate or polysilicon)) and (gate with (thin\$4 or narrow or slim\$4))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:07

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L11	39	L10 not L5	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:07
L12	195	L9 not l10	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:09
L13	195	L12 not L5	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 23:09
S1	1391	(@ad<"20040126") and 438/176,275, 587.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:18
S2	31580	(@ad<"20040126") and "438"/\$.ccls. and ((pattern\$3 or etch\$3) with (gate or polyisilicon))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:19
S3	1020	S1 and ((pattern\$3 or etch\$3) with (gate or polyisilicon))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:19
S4	1097	S1 and ((pattern\$3 or etch\$3) with (gate or polysilicon))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:23

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S5	1310	438/142,585.ccls. and ((pattern\$3 or etch\$3) with (gate or polysilicon))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 22:58
S7	1110	S5 and (resist or photoresist or mask)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:24
S8	560	S7 and plasma	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:25
S9	556	S8 and gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/21 19:25

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